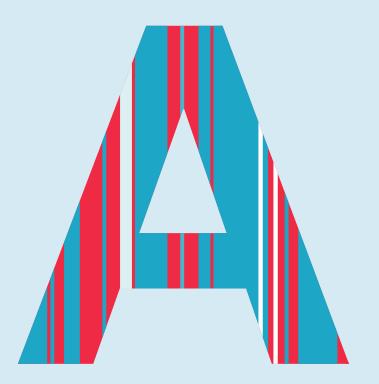
YOUR VISION. OUR INSPIRATION





SW 2.4.0

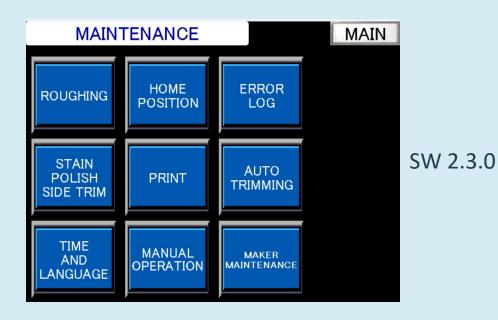
Log-in function.

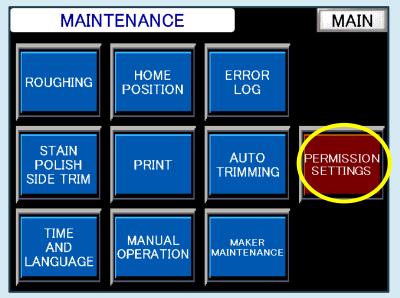


The AS-410M now supports User ID login functionality, enabling greater control and security.

Key Features:

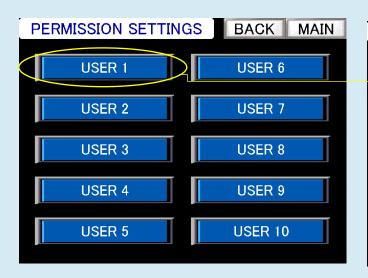
- Up to 10 Unique User IDs
 Create and manage login credentials for up to 10 different users.
- Customizable Access Permissions
 Define individual access levels and permissions for each user,
 allowing tailored control based on roles or responsibilities.

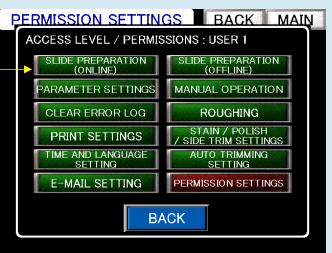




SW 2.4.0



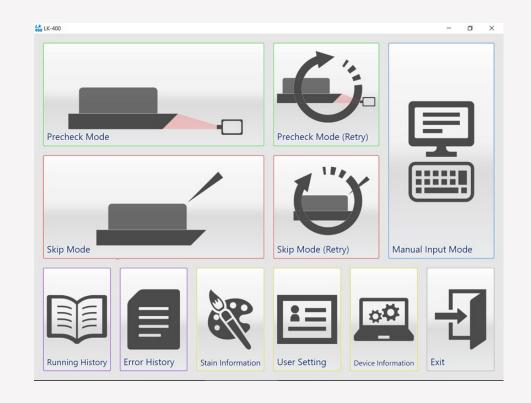




And select the level of permission

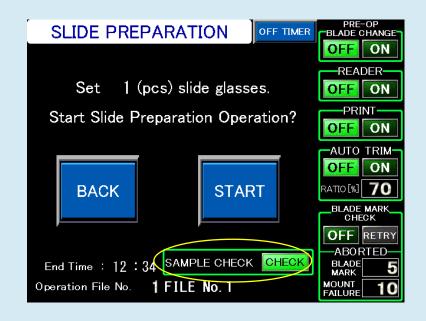


LK400 update





Deactivate Sample Check at Offline Operation.



Green CHECK: Sample will be checked **Yellow SKIP:** Samples will not be checked.

Press to change between the two options.

The AS-410M is now allowing flexibility in offline operations.

What's Changed:

Before:

The unit automatically performed a sample block check to ensure that the selected blocks matched those placed on the trays before starting any offline slide preparation.

Now:

Users can bypass the block matching check, allowing the unit to begin offline slide preparation immediately—without verifying the block selection. If a selected position doesn't have a block, it would be skipped.

Blade Exchange During Operation

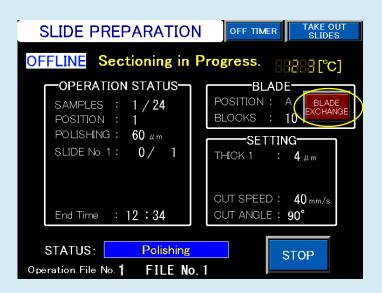
The system now supports blade changes without stopping the overall operation, giving users more control and flexibility.

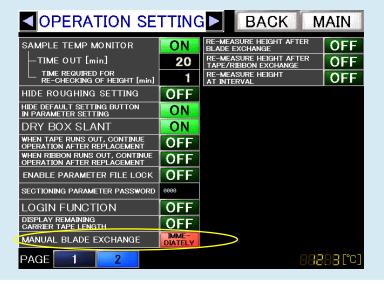
New Blade Change Options:

You can now choose when the blade change should occur:

Immediate Change – The blade is replaced as soon as the command is given.

At Sample Change – The blade change is automatically triggered during the next sample switch, minimizing workflow interruption.







BLK Block Count Setting Method Changed.

The blade condition information is now presented in a more detailed and user-friendly way.

Now:

The interface shows exactly how many blocks have been processed with each blade.

It also displays the number of consecutive serial sections allowed per blade position.

"roughing is now included in the overall count of blocks used per blade"

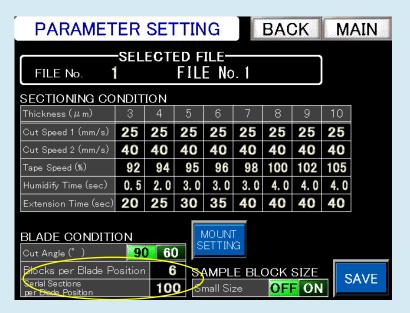
Previously:

The display only showed basic indicators such as:

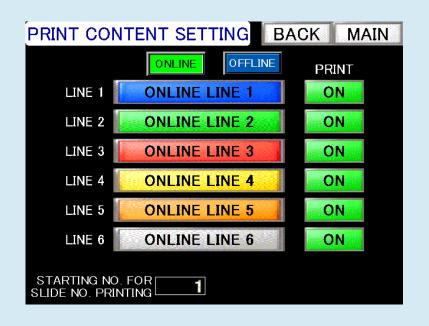
BLK

BLK (R)

Sections per blade position



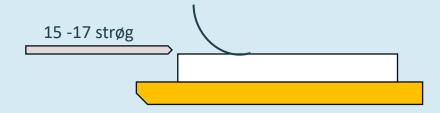
Bugfixes: Bug Fix for Slide Number Printing Start Value Setting and Bug Fix for Online Interval Blade Exchange Function.





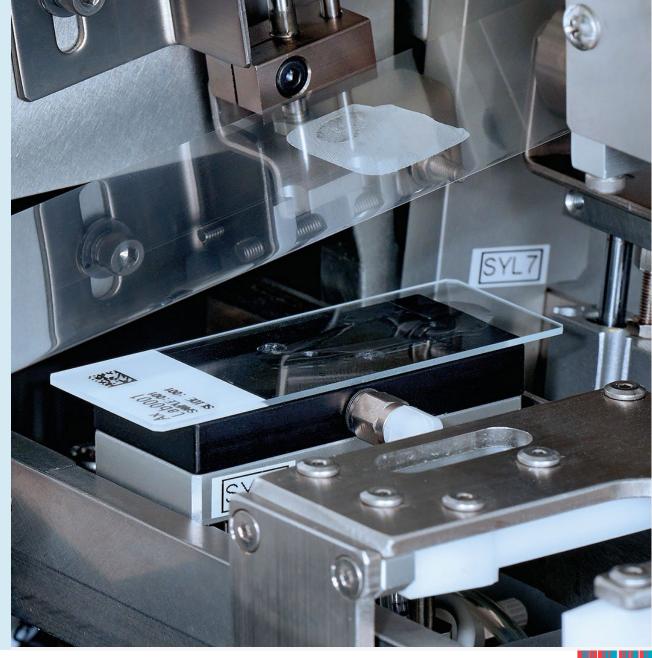
Polish settings på AS-410M

"De antal µm som det kræver at tilpasse blok og kniv"



Typiske værdi ligger omkring $80-100\mu m$

Afhængig af værdien er dette ofte 15-17 knivstrøg.



De tre test sites:



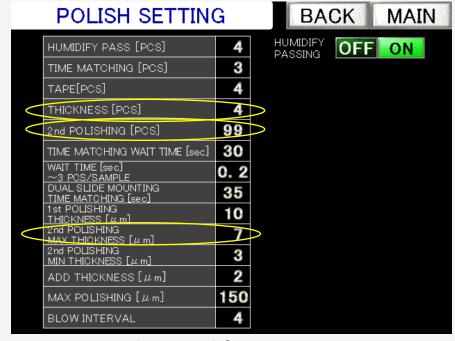
- Polish værdi: 80μm
- 2nd polish max 7μm
- Tid for 24 blokke: 1t



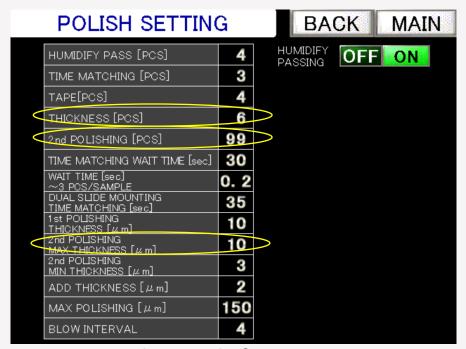
- Polish værdi: 80-90μm
- 2nd polish max 7μm
- Tid for 24 blokke: 1t



- Polish værdi: 100μm
- 2nd polish max 12μm
- Tid for 24 blokke: 1t



Eksempel før justering.



Eksempel efter justering.

Antallet af steps afhænger af tykkelsen.

```
PolishCut No.01 Thickness = 5[\mu m] (2nd Polishing)
                                                                             PolishCut No.01 Thickness = 7[µm] (2nd Polishing)
                                                                                                                                                          PolishCut No.01 Thickness = 10[μm] (2nd Polishing)
                                                                                                                                                                                                                                        PolishCut No.01 Thickness = 14[um] (2nd Polishing)
PolishCut No.02 Thickness = 5[um] (2nd Polishing)
                                                                             PolishCut No.02 Thickness = 7[µm] (2nd Polishing)
                                                                                                                                                          PolishCut No.02 Thickness = 10[μm] (2nd Polishing)
                                                                                                                                                                                                                                        PolishCut No.02 Thickness = 14[\mu m] (2nd Polishing)
PolishCut No.03 Thickness = 5[µm] (2nd Polishing)
                                                                             PolishCut No.03 Thickness = 7[μm] (2nd Polishing)
                                                                                                                                                          PolishCut No.03 Thickness = 10[μm] (2nd Polishing)
                                                                                                                                                                                                                                        PolishCut No.03 Thickness = 14[\mu m] (2nd Polishing)
PolishCut No.04 Thickness = 5[\mu m] (2nd Polishing)
                                                                             PolishCut No.04 Thickness = 7[µm] (2nd Polishing)
                                                                                                                                                          PolishCut No.04 Thickness = 10[μm] (2nd Polishing)
                                                                                                                                                                                                                                        PolishCut No.04 Thickness = 14[µm] (2nd Polishing)
PolishCut No.05 Thickness = 5[μm] (2nd Polishing)
                                                                             PolishCut No.05 Thickness = 7[µm] (2nd Polishing)
                                                                                                                                                          PolishCut No.05 Thickness = 10[μm] (2nd Polishing)
                                                                                                                                                                                                                                        PolishCut No.05 Thickness = 6[µm] (MakingThickness+Additional Polishing)
PolishCut No.06 Thickness = 5[µm] (2nd Polishing)
                                                                                                                                                          PolishCut No.06 Thickness = 6[µm] (2nd Polishing)
                                                                             PolishCut No.06 Thickness = 7[µm] (2nd Polishing)
                                                                                                                                                                                                                                        PolishCut No.06 Thickness = 4[µm] (MakingThickness Polishing)
PolishCut No.07 Thickness = 5[µm] (2nd Polishing)
                                                                             PolishCut No.07 Thickness = 7[µm] (2nd Polishing)
                                                                                                                                                          PolishCut No.07 Thickness = 6[µm] (MakingThickness+Additional Polishing)
                                                                                                                                                                                                                                        PolishCut No.07 Thickness = 4[µm] (MakingThickness Polishing) <Tape Mount>
PolishCut No.08 Thickness = 5[µm] (2nd Polishing)
                                                                             PolishCut No.08 Thickness = 7[\mu m] (2nd Polishing)
                                                                                                                                                          PolishCut No.08 Thickness = 4[µm] (MakingThickness Polishing)
                                                                                                                                                                                                                                        PolishCut No.08 Thickness = 4[μm] (MakingThickness Polishing) <Tape Mount>
PolishCut No.09 Thickness = 5[\mu m] (2nd Polishing)
                                                                             PolishCut No.09 Thickness = 6[\mu m] (MakingThickness+Additional Polishing)
                                                                                                                                                          PolishCut No.09 Thickness = 4[µm] (MakingThickness Polishing) <Tape Mount>
                                                                                                                                                                                                                                        PolishCut No.09 Thickness = 4[µm] (MakingThickness Polishing) <Tape Mount>
PolishCut No.10 Thickness = 5[µm] (2nd Polishing)
                                                                             PolishCut No.10 Thickness = 4[µm] (MakingThickness Polishing)
                                                                                                                                                          PolishCut No.10 Thickness = 4[µm] (MakingThickness Polishing) <Tape Mount>
                                                                                                                                                                                                                                        PolishCut No.10 Thickness = 4[μm] (MakingThickness Polishing) <Tape Mount>
PolishCut No.11 Thickness = 5[\mu m] (2nd Polishing)
                                                                             PolishCut No.11 Thickness = 4[μm] (MakingThickness Polishing) <Tape Mount>
                                                                                                                                                          PolishCut No.11 Thickness = 4[µm] (MakingThickness Polishing) <Tape Mount>
PolishCut No.12 Thickness = 6[µm] (MakingThickness+Additional Polishing)
                                                                             PolishCut No.12 Thickness = 4[μm] (MakingThickness Polishing) <Tape Mount>
                                                                                                                                                          PolishCut No.12 Thickness = 4[µm] (MakingThickness Polishing) <Tape Mount>
PolishCut No.13 Thickness = 4[µm] (MakingThickness Polishing)
                                                                             PolishCut No.13 Thickness = 4[µm] (MakingThickness Polishing) < Tape Mount>
PolishCut No.14 Thickness = 4[μm] (MakingThickness Polishing) <Tape Mount>
                                                                             PolishCut No.14 Thickness = 4[μm] (MakingThickness Polishing) <Tape Mount>
PolishCut No.15 Thickness = 4[µm] (MakingThickness Polishing) <Tape Mount>
PolishCut No.16 Thickness = 4[μm] (MakingThickness Polishing) <Tape Mount>
PolishCut No.17 Thickness = 4[µm] (MakingThickness Polishing) <Tape Mount>
                                                                                                                                               2nd polish max from
                                                      2nd polish max
                                                                                                                                               5\mu m \rightarrow 14\mu m
                                                      from 5\mu m \rightarrow 7\mu m
                                                                                                                                               Saves 7 polish steps
                                                       Saves 3 polish
                                                       steps
```

Hvad hvis vi kunne reducere disse steps?



- Polish værdi: 80μm
- 2nd polish max: 7μm
- Tid for 24 blokke: 1t og 1m

Ændringer:

- 2nd polish max: 10μm
- Tid for 24 blokke: 50-55min



- Polish værdi: 80-90μm
- 2nd polish max: 7μm
- Tid for 24 blokke: 1t

Ændringer:

- 2nd polish max: 14μm
- Tid for 96 blokke: 23min reducering.
- SNMAM: 3→ 4 blokke i timen.
- SNM: $2 \rightarrow 3$ blokke i timen

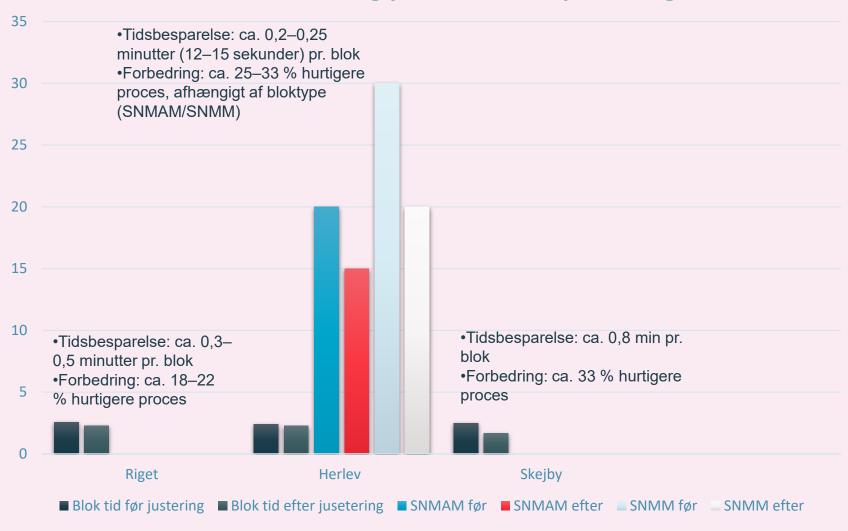


- Polish værdi: 100μm
- 2nd polish max: 12μm
- Tid for 24 blokke: 1t

Ændringer:

- 2nd polish max: 14μm
- Polish værdi fra
 100μm →80μm.
- Tid for 2 trays: 1,33 time ca.

Procesforbedring pr. blok efter optimering



Hvad skal vi huske på.

2nd polish max

Undgå at sætte for højt, så vacuum-systemet ikke kan følge med.

Snit- og vævskvalitet

Sørg for, at ændringer i polish ikke påvirker vævet negativt eller kompromitterer snitkvaliteten.

Konsistens i snittykkelse

Når trinnene gøres grovere, skal man sikre, at flere snit har samme tykkelse.

Fokus på kvalitet frem for hastighed

Husk, at AS-410M er primært associeret med kvalitet, ikke hastighed.